

AUG 02 2005

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Docket No.: SON-2628

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Shinji OMORI, et al.

Application No.: 10/509,230

Filing Date: September 24, 2003

For: MASK PATTERN CORRECTION
METHOD, PRODUCTION METHOD OF
SEMICONDUCTOR DEVICE, MASK
PRODUCTION METHOD AND MASK

Group Art Unit: 2812

Confirmation No.: 1800

REQUEST FOR CORRECTED FILING RECEIPT

Attention: Fax: 703-746-9195
Office of Initial Patent Examination's
Filing Receipt Correction

Commissioner for Patents
P.O. Box 1450
Washington, D.C. 22313-1450

Sir:

1. Attached is a copy of the official filing receipt received from the PTO in the above application for which issuance of a corrected filing receipt is respectfully requested.
2. There is an error with respect to the following, which is incorrectly entered. We are also enclosing a copy of the executed declaration showing the correct data.

Error:

TITLE

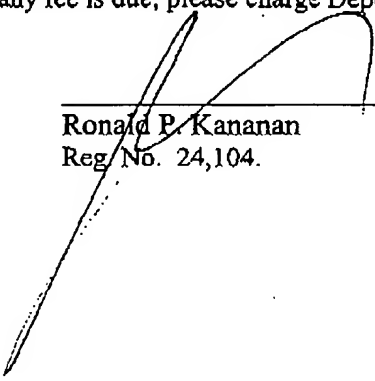
Correct data to title:

Mask pattern correction method, production method
of semiconductor device, mask production method
and mask

3. The correction is due to an error by the USPTO. If any fee is due, please charge Deposit Account No. 18-0013.

Dated: February 23, 2005

Rader, Fishman & Grauer, PLLC
1233 20th Street, N.W., Suite 501
Washington, DC 20036
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Ronald P. Kananan
Reg. No. 24,104.

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/509,230	09/24/2004	2812	1200	SON-2628	24	26	5

23353
RADER FISHMAN & GRAUER PLLC
LION BUILDING
1233 20TH STREET N.W., SUITE 501
WASHINGTON, DC 20036

CONFIRMATION NO. 1800

FILING RECEIPT

OC000000015145335

Date Mailed: 02/14/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Assignment For Published Patent Application

Sony Corp., Tokyo, JAPAN

Power of Attorney:

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Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/03455 03/20/2003

Foreign Applications

JAPAN 2002-92612 03/28/2002

Projected Publication Date: 05/19/2005

Non-Publication Request: No

Early Publication Request: No

Title

Mask pattern correction method, semiconductor device manufacturing method, mask manufacturing method and mask

Preliminary Class

438

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